

Form PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION <i>(Use several sheets if necessary)</i>		Docket Number (Optional) 2919.1US (96-0499.01)		Application Number <u>09/</u> To be assigned <u>072955</u>	
Applicant <u>Pai-Hung Pan</u>				Filing Date <u>May 5, 1998</u>	
				Group Art Unit <u>To be assigned 2823</u>	

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	NAME	DATE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
<u>G</u>	4,786,954	Morie et al.	11/22/88	—	—	
<u>G</u>	4,849,344	Desbiens et al.	07/18/89	—	—	
<u>G</u>	5,173,439	Dash et al.	12/22/92	—	—	
<u>G</u>	5,272,117	Roth et al.	12/21/93	—	—	
<u>G</u>	5,296,392	Gula et al.	03/22/94	—	—	
<u>G</u>	5,297,082	Lee	03/22/94	—	—	
<u>G</u>	5,346,587	Doan et al.	09/13/94	—	—	
<u>G</u>	5,433,794	Fazan et al.	07/18/95	—	—	
<u>G</u>	5,436,488	Poon et al.	07/25/95	—	—	
<u>G</u>	5,459,096	Venkatesan et al.	10/17/95	—	—	
<u>G</u>	5,492,858	Bose et al.	02/20/96	—	—	
<u>G</u>	5,516,625	McNamara et al.	05/14/96	—	—	
<u>G</u>	5,516,721	Galli et al.	05/14/96	—	—	
<u>G</u>	5,521,422	Mandelman et al.	05/28/96	—	—	

FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS		(Including Author, Title, Date, Pertinent Pages, Etc.)
		Davari, et al., "A Variable-Size Shallow Trench Isolation (STI) Technology With Diffused Sidewall Doping For Submicron CMOS", <i>IEEE IEDM</i> (1988).
		K. Blumenstock et al., "Shallow Trench Isolation for Ultra-Large-Scale Integrated Devices", <i>J. Vac. Sci. Technol.</i> , B 12(1) (Jan/Feb 1994).

EXAMINER <div style="font-size: 1.5em; font-family: cursive; text-align: center;">FOURSON</div>	DATE CONSIDERED <div style="font-size: 1.5em; font-family: cursive; text-align: center;">11/7/99</div>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

Form PTO-1449

**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION**

(Use several sheets if necessary)

Docket Number (Optional)
2919.1US

Application Number
09/072,959
Applicant **Pai-Hung Pan**Filing Date **May 5, 1998**Group Art Unit **2811 2823**
U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
G	4,307,180	12/1981	Pogge	—	—	
G	5,677,233	10/1997	Abiko	—	—	
G	5,712,185	01/1998	Tsai et al.	—	—	
G	5,801,083	09/1998	Yu et al.	—	—	
G	5,811,346	09/1998	Sur et al.	—	—	
G	5,834,358	11/1998	Pan et al.	—	—	

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

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